

IN THE SPECIFICATION

Please replace the paragraph on page 15 at lines 19-22 through page 16 at lines 1-3 of the specification with the following replacement paragraph:

In FIG. 15, a portion of yoke layer materials is shown removed from the ion milling process. A yoke 1504 is thereby formed over the front and back gap connecting pedestals 1202 and 1204. In FIG. 15, the yoke 1504 is revealed to have the laminated materials made of alternating magnetic and dielectric layers formed previously in relation to FIG. 14. From the further ion milling, a small portion of insulator materials 1506 may remain formed around front P2 pole tip 1114. Photoresist mask 1404 may be removed by dissolving photoresist layer 1406 and release layer 1408 with a suitable solvent. The method may continue using conventional head processing to complete the formation of the head.